## NSN 6630-01-291-7548

Planar Plasma Etcher - Page 1 of 1



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For anisotropic etching of electron devices for failure analysis laboratories; bu	uilt-in vacuum gauge, built-in pyrex chamber (replacable)
w/lift-top design for easy loading and two gas valves making possible the mixir	ng of 2 reactive gasses when desired

Shelf Life:

N/a

**Unit Of Measure:** 

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Demilitarization:

No